shown by paper chromatography (in a propylene glycol-toluene system) as a very slowly moving spot.

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¹ Nature, 164, 443 (1949).

Detection of Iodine-containing Compounds on Paper Chromatograms

Bowden, Maclagan and Wilkinson have described¹ the use of the ceric sulphate - arsenious acid reaction for the detection of micro-quantities of iodinecontaining compounds on paper chromatograms. A difficulty encountered in this laboratory was the fading of the background colour due to the presence of traces of iodine in the atmosphere. This can be prevented by spraying the chromatograms, immediately on completion of the catalytic reaction, with a 1 per cent solution of o-phenylenediamine in acetone The stable chocolate-coloured and drying in air. background formed by reaction of excess ceric sulphate with the amine gives a greatly increased contrast with the white spots, and the life of the chromatogram is limited only by the decomposition of the cellulose by the acid present in the original reagent.

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¹ Bowden, C. H., Maclagan, N. F., and Wilkinson, J. H., Biochem. J., 59, 93 (1955).

The System Niobium-Silicon and the Effect of Carbon on the Structures of **Certain Silicides**

THE phase diagram of the niobium-silicon system has been established by melting-point determinations, X-ray examination and metallography, and is shown in Fig. 1. Alloys were prepared in the form of beads weighing 1-2 gm. by melting the constituents together in an argon arc-furnace¹: the metals used were 'Matthey' standards and the silicon was Johnson, Matthey and Co.'s 'Hyperpure'. Meltingpoint measurements were made in the furnace by a technique described earlier².

Three intermediate phases, Nb_4Si , Nb_8Si_3 and $NbSi_2$, are present in the system. That of composition Nb_4Si is formed peritectically at about 1,950° C. from Nb_5Si_3 and the melt. From metallographic and X-ray examinations, it is evident that this compound is isomorphous with Ta₄Si and Zr₄Si, but the DO_{19} structure of the Ta₄Si phase reported by Kieffer, Benesowsky, Nowotny and Schachner³ has not been detected in alloys arc-melted from components of high purity. The phase Nb_sSi_3 melts congruently at 2,480° C., and exists in two modifications, ' α -Nb_sSi₃' stable at low temperatures, and ' β -Nb_sSi_s' the high-temperature phase. The α - β transformation lies between 1,900° and 2,100° C. Phases with structures corresponding to α - and β -Nb₅Si₃ have been found in systems of silicon with the neighbouring transition metals of Groups IV, V and VI. Powder photographs of arc-melted specimens of VsSi3, CrsSi3, MosSi3 and WsSi3 suggest that these compounds are isomorphous with the β -form of Nb₅Si₃, and that arc-melted Ta₅Si₃ is isomorphous



Fig. 1. Niobium - silicon system. •, Observed melting points

with the α -form. In an investigation of alloys prepared by hot-pressing in graphite moulds, Schachner, Cerwenka and Nowotny⁴ determined the structures of several silicides of the composition M₅Si₃. They reported that V₅Si₃, Mo₅Si₃ and Nb₅Si₃ had the D8₈ structure, but this structure was not found in the arc-melted silicides used in the present work. Carbon is a very probable contaminant in hot-pressed samples, and to determine whether carbon contamination accounts for the discrepancy in results, the M5Si2 silicides were re-melted in the arc furnace with 1-2 wt. per cent of coconut charcoal. In all cases the addition of carbon caused the formation of D88 structures.

The melting point of NbSi₂ has been determined as 1,930° C., and a eutectic is formed between this compound and Nb₅Si₃ at 1,850° C. and 58 atomic per cent silicon. At the niobium end of the diagram, silicon lowers the liquidus to about 1,880° C., the eutectic temperature between Nb₄Si and niobium. The terminal solubilities of silicon in niobium and niobium in silicon have not been investigated. An appreciable solubility of silicon in niobium is probable, a lattice expansion of 3.2993-3.3088 kX. being observed in powder compacts sintered at 1,300° C. I thank Dr. G. A. Geach for suggesting this

investigation, and for his continued interest in it, and also Dr. T. E. Allibone, director of the Associated Electrical Industries Research Laboratory, for permission to publish this communication.

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